Electronic supplementary information (ESI)

Elastomers with tunable dielectric and electromechanical properties

Simon J. Dünki, Frank A. Nüesch, and Dorina M. Opris*

S. J. Dünki, Prof. F. A. Nüesch, Dr. D. M. Opris, Swiss Federal Laboratories for Materials Science and Technology Empa, Laboratory for Functional Polymers, Ueberlandstr. 129, CH-8600, Dübendorf, Switzerland E-mail: dorina.opris@empa.ch
S. J. Dünki, Prof. F. A. Nüesch
Ècole Polytechnique Fédérale de Lausanne (EPFL), Institut des matériaux, Station 12, CH 1015, Lausanne, Switzerland



Figure S1. IR spectra of the two film surfaces of different materials (top layer exposed to the glass plate and down layer exposed to the Teflon substrate) (left) and of the ground films in KBr (right).



Figure S2. TGA curves of M(x:y) conducted at a heating rate of 20 °C min⁻¹ under nitrogen.





Figure S3. DSC curves of different materials M(x:y). An increase in T_g with CN content can be seen.

Calculation of the Weibull parameter for M(1:0) when the Weibull location parameter γ is not neglected. From the Weibull plot the two extreme points on the y axis with the corresponding E_b values (a and b) are taken. The physical distance on the y axis was divided by two and the corresponding E_b value (c) was found. (Figure S4).



Figure S4. determination of a, b and c values required to estimate γ .

 γ was calculated according to equation (1):

$$\gamma = c - \frac{(b-c)(c-a)}{(b-c) - (c-a)} \tag{1}$$

and found to be 27.4.

This value was included in the calculation for the Weibull plot from which β and η_p were obtained as previously described in the paper (Figure S5). The location parameter γ has to be added to η_p to obtain the scale parameter η



Figure S5. Weibull plot for M(1:0) considering γ . Dotted line represents the linear fit.

Sample	Dielectric	E _b	Weibull β-	Weibull η-	Weibull γ-	Weibull plot	R ² of linear fit
	breakdown	Stab	parameter	parameter	parameter	Intercept	
M(1:0)	33.8	4.3	1.6	34.7	27.5	-3.15	0.97



Figure S6. Stress-strain curves for material M(1:0) from standard tensile tests at various initial strain rates (0.463 s⁻¹, 0.0463 s⁻¹, 0.00463 s⁻¹, and 0.00463 s⁻¹).



Figure S7. Stress-strain curves for material M(3:1) from standard tensile tests at various initial strain rates (0.463 s⁻¹, 0.0463 s⁻¹, 0.00463 s⁻¹, and 0.00463 s⁻¹).



Figure S8. Stress-strain curves for material **M(1:1)** from standard tensile tests at various initial strain rates $(0.463 \text{ s}^{-1}, 0.0463 \text{ s}^{-1}, 0.00463 \text{ s}^{-1}, \text{ and } 0.00463 \text{ s}^{-1})$.



Figure S9. Stress-strain curves for material **M(1:3)** from standard tensile tests at various initial strain rates $(0.463 \text{ s}^{-1}, 0.0463 \text{ s}^{-1}, 0.00463 \text{ s}^{-1}, \text{ and } 0.00463 \text{ s}^{-1})$.



Figure S10. Stress-strain curves for material **M(1:0)** from standard tensile tests at various initial strain rates $(0.463 \text{ s}^{-1}, 0.0463 \text{ s}^{-1}, 0.00463 \text{ s}^{-1})$ and $0.00463 \text{ s}^{-1})$.



Figure S11. Stress-strain curves for materials M(x:y) from standard tensile tests at initial strain rate of 0.0463 s⁻¹ after the synthesis and after 1 year. A slight increase in the stiffness after one year aging can be seen.



Figure S12. Stress-strain curves for materials M(x:y), VHB and Elastosil from standard tensile tests at 50 mm min⁻¹. The stress-strain curves were averaged from three independent tests.



Figure S13. Lateral actuation strain as function of electric field for materials M(x:y), Elastosil and VHB which were 28.6% biaxial prestrained except VHB for which 300% bilateral strain was used.